

EXPRESS MAIL NO. EL844534677US, MAILED 10/30/01
M063573 Sh. 1 of 6
Attenuating Phase Shift Mask for Photolithography
Inventor or Identifier: Rothschild, et al.

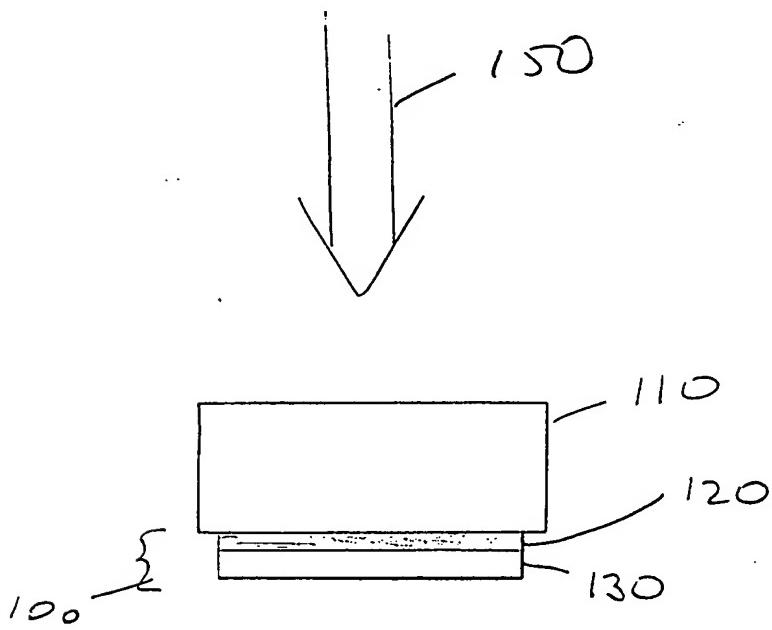


FIG. 1

1002042-120701

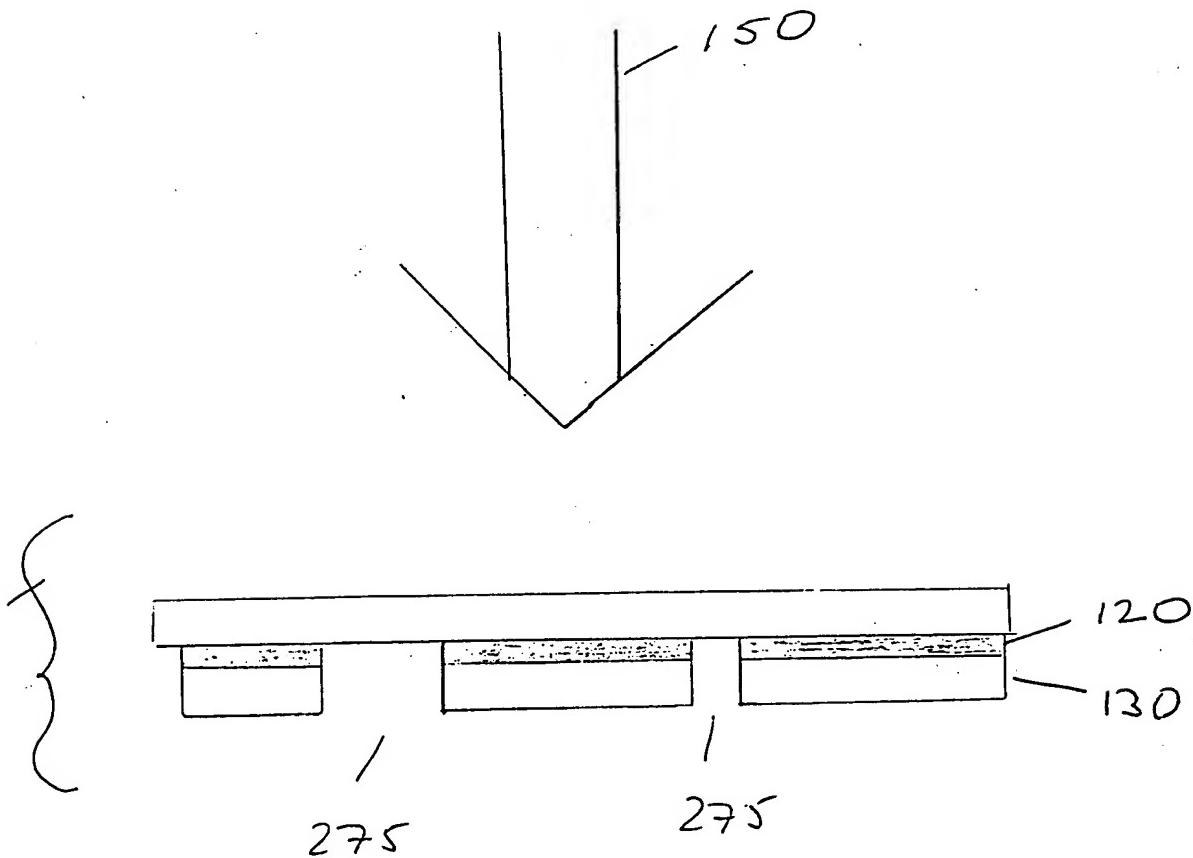
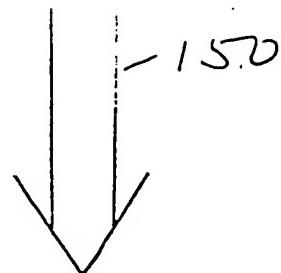


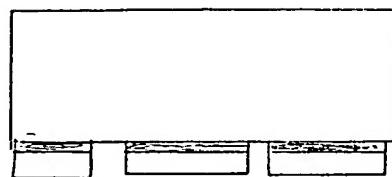
FIG. 2

EXPIRES MAIL NO. EL844534677US, MAILED 12/20/2001
M06357073 S. 3 of 6
Attenuating Phase Shift Mask for Photolithography
Inventor or Identifier: Rothschild, et al.

300



-150



-200



335



350

FIG. 3

10020042-120201

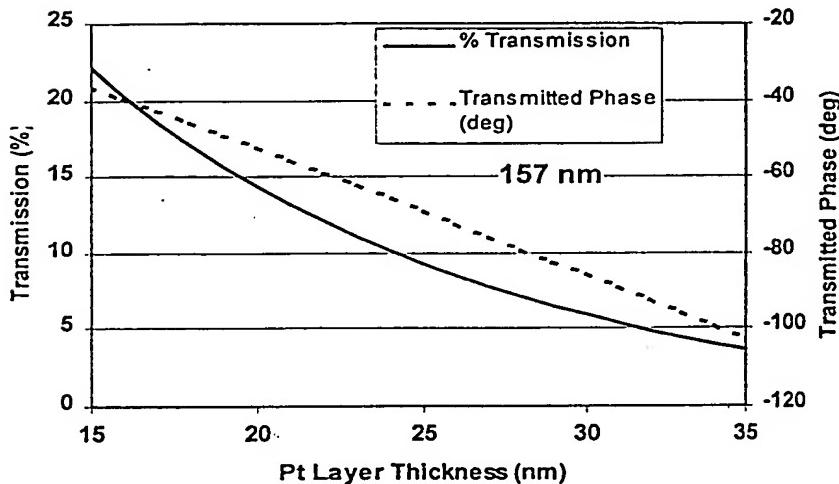


FIG 4a

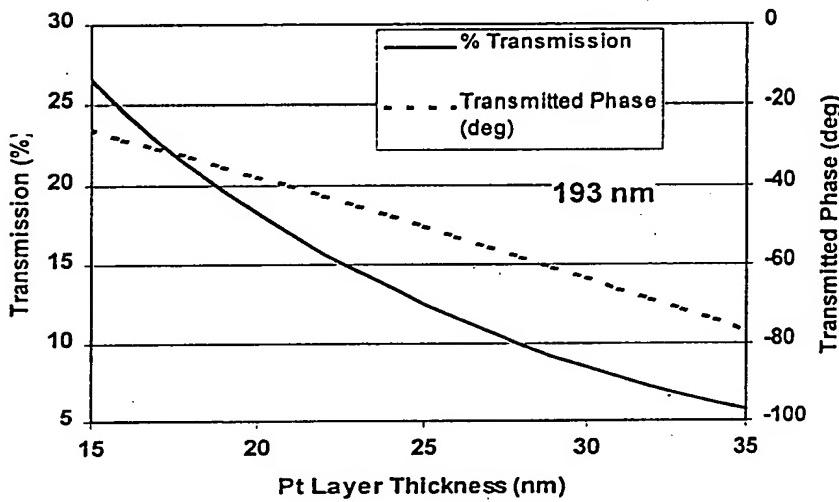


FIG 4b

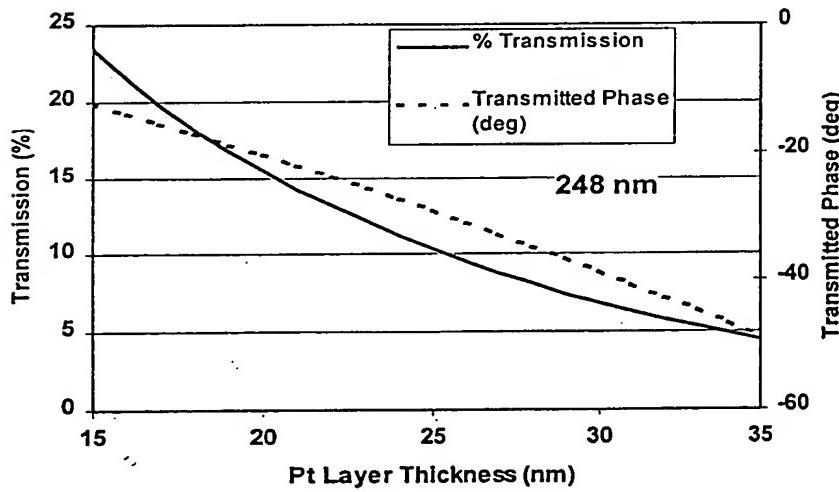


FIG 4c

500

TOP SECRET "2400001"

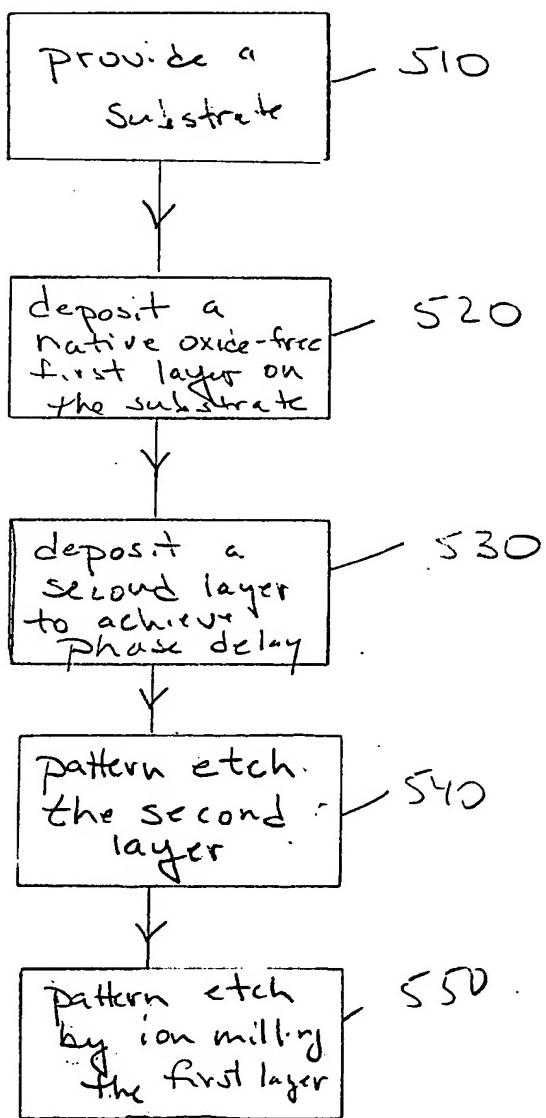


FIG 5a

SSD

1000200042002020

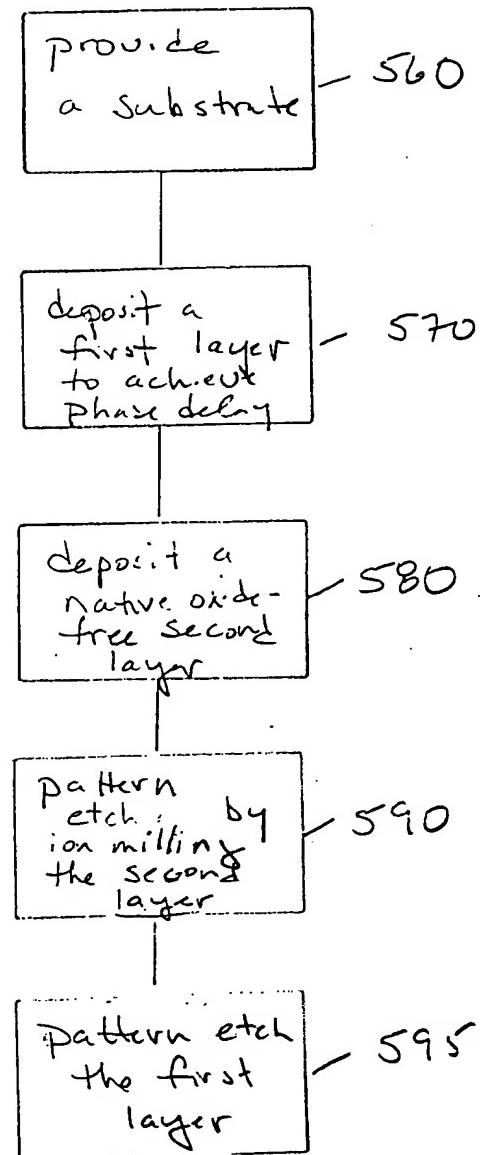


FIG 5b